NOTES:

1. SUBSTRATE MATERIAL: FUSED SILICA

- 2. SURFACE S2 TO BE PARALLEL TO SURFACE S1 TO WITHIN <3 ARCMIN
- 3. COATING (APPLY ACROSS CLEAR APERTURE)

S1: DIELECTRIC

Rs>99.9% @385-415nm

Rp>99.8% @395-415nm

Rs>99.9% @770-830nm

Rp>99.9% @770-820nm

S2: STRESS-COMPENSATING

GROUP DELAY DISPERSION

<35fs2 @ 385 - 415nm (s-pol)

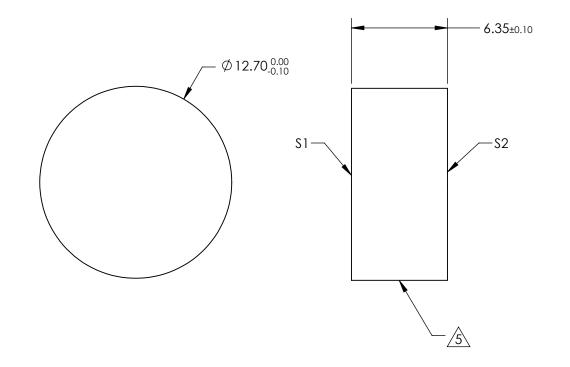
<50fs2 @ 395 - 415nm (p-pol)

<20fs2 @ 770 - 830nm (s-pol)

<40fs2 @ 770 - 810nm (p-pol)



5. ROHS COMPLIANT



FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

SHAPE	S1 PLANO	S2 PLANO		B	Edmund Optics®
SURFACE FLATNESS	λ/6	N/A			400, 800nm, 12.7mm Dia., Ultrafast Dual Band
SURFACE QUALITY	10 - 5	COMMERCIAL POLISH	THIRD ANGLE PROJECTION	TITLE	Mirror
CLEAR APERTURE	Ø 10.92	N/A	'		CHEET
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	ALL DIMS IN mm	DWG NO	24321 SHEET 1 OF 3